



NOTES

1. MATERIAL: UVFS
2. COATING(S1): UVAL
 $R_{\text{avg}} > 90\% @ 250\text{ nm} - 450\text{ nm}, 0^\circ - 45^\circ \text{ AOI}$
3. CLEAR APERTURE(S1): $> 90\% \text{ CA}$
4. SURFACE QUALITY(S1): $40/20(\text{S/D})$
5. SURFACE FLATNESS(S1): $\lambda/10 @ 633\text{ nm}$
6. CHAMFER: $0.2\text{ mm}, 45^\circ$
7. BACK SURFACE (S2): FINE GROUND

DRAWING PROJECTION			LBTEK			
	NAME	DATE				
DRAWN	SHAN	FEB./6th/25	UVAL-COATED D MIRROR			
APPROVAL	WCHENG	FEB./6th/25	MATERIAL	WEIGHT	SCALE	REV
FOR INFORMATION ONLY NOT FOR MANUFACTURING PURPOSES			UVFS	2.86g	5:1	C